

PATENT

**RESPONSE UNDER 37 C.F.R. 1.116 - EXPEDITED
PROCEDURE - EXAMINING GROUP 2891**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No.:	10/808,692	Confirmation No.:	6062
Applicant(s):	Ogihara et al.		
Filed:	03/25/2004		
Art Unit:	2891		
Examiner:	A. Sarkar		
Title:	COMPOSITION FOR FORMING POROUS FILM, POROUS FILM AND METHOD FOR FORMING THE SAME, INTERLEVEL INSULATOR FILM AND SEMICONDUCTOR DEVICE		

Docket No.: 035576/276101
Customer No.: 00826

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Commissioner for Patents
P.O. Box 1450
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REPLY AFTER FINAL UNDER 37 CFR § 1.116

Sir:

In response to the final Office Action dated March 20, 2006, please consider the following remarks:

Remarks/Arguments begin on page 2 of this paper.